



Docket No. 11675.107

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And +

David Y. Kao et al. ✓

Art Unit 3/11/03
2823

OXIDATION OF ION IMPLANTED
SEMICONDUCTORS

Examiner: George R. Fourson III

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In response to the Office Action mailed from the United States Patent and Trademark Office on November 20, 2002, please enter the following amendments and remarks into the file of the above-identified application.

Please amend the claims as follows: